

### ABSTRACT

An embodiment of the instant invention is a method of oxidizing a first feature (feature 108 and/or feature 104 of FIGURE 1 and feature 314 of FIGURE 3) while leaving a second feature substantially unoxidized (features 110 and 112 of FIGURE 1 and features 310 and 312 of FIGURE 3), the method comprised of subjecting the first and second features to an oxygen-containing gas and a separate hydrogen-containing gas. Preferably, the oxygen-containing gas is comprised of a gas selected from the group consisting of:  $O_2$ ,  $N_2O$ ,  $CO_2$ ,  $H_2O$ , and any combination thereof, and the hydrogen-containing gas is comprised of  $H_2$ . The first feature is, preferably, comprised of polycrystalline silicon, silicon oxide, or a dielectric material, and the second feature is, preferably, comprised of tungsten.

09173129-101598